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PATENT

DOCKET NO.: 29284/592

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventors : Hideki SAGA

Serial No. : 10/622,450

Filed : 21 July 2003

For : INFORMATION RECORDING APPARATUS

Group Art Unit: 2655

Conf. No. 5239

Examiner :

COMMISSIONER FOR PATENTS
P. O. Box 1450
Alexandria, Virginia 22313-1450

**INFORMATION DISCLOSURE STATEMENT
UNDER 37 C.F.R. § 1.97 & § 1.98**

S I R:

In conformance with Applicant's duty of disclosure under 37 C.F.R. § 1.56 and § 1.97(b)(3), the references listed on the attached form PTO-1449 are hereby brought to the Examiner's attention.

The references were cited in an Office Action issued by the Chinese Patent Office on 6 August 2004. A copy of the Office Action is enclosed. An English Abstract is attached to the Chinese language publication.

It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the references be made of record therein and appear in the "references cited" on any patent to issue therefrom.

Respectfully submitted,

John C. Altmiller
(Reg. No. 25,951)

Date: 4 October 2004

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**FORM PTO-1449
INFORMATION DISCLOSURE
STATEMENT BY APPLICANT(S)**

Atty Docket No.: 29284/592
Serial No. : 10/622,450
Applicants : Hideki SAGA
Filed : 21 July 2003
Group Art Unit : 2655
Examiner :



U.S. PATENT DOCUMENTS

Examiner Initial	Patent Number	Patent Date	Name	Class/ Subclass	Filing Date
	6,125,084	09/26/00	SUKEDA et al.	369/13	

FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class/ Subclass	Translation Yes No
	1197530A	10/29/98	China		ABS.

OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent Pages, Etc.)

Examiner
Initial

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.